

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	10876	TMAH or (teramethylammonium adj hydroxide) or (tetramethyl adj ammonium adj hydroxide) or tetramethylammoniumhydroxide or (tetra adj methyl adj ammonium adj hydroxide)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/22 14:20
L5	1240	1 same ((solvent with organic) or glycol or alcohol or isopropanol or butanol or hexanol or phenol or glycerol or ethyleneglycol propyleneglycol or glycerin)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/22 14:33
L6	6051	1 and ((solvent with organic) or glycol or alcohol or isopropanol or butanol or hexanol or phenol or glycerol or ethyleneglycol propyleneglycol or glycerin)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/22 14:33
L7	5259	6 and (@ad<"20040319" or @rlad<"20040319")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/22 14:34
L8	1431	7 and ((silicon or Si or HAZ or ((heat\$6 or laser\$6 or thermal) near5 (damag\$6 or effect\$6))) near20 (etch\$6 or clean\$6 or remov\$6))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/22 14:35
L9	1254	8 and (nitride or oxide or bondpad or passivat\$6 or polyimide or SiO2 or SiO?sub\$2 or SiN)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/22 14:35
L10	1243	9 and (semiconductor or wafer or substrate or chip or die or dice)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/22 14:37
L11	277	10 and 5	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/12/22 14:37